

# Chemical Vapor Deposition of Ta<sub>2</sub>O<sub>5</sub> Corrosion Resistant Coatings

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## Abstract

Silicon carbide and silicon nitride heat engine components are susceptible to hot corrosion by molten Na<sub>2</sub>SO<sub>4</sub> which forms from impurities present in fuel and the environment. Chemically vapor deposited Ta<sub>2</sub>O<sub>5</sub> coatings are being developed as a means to protect components from reaction with these salts and preserve their structural properties. Investigations to optimize the structure of the coating have revealed that the deposition conditions dramatically affect the coating morphology. Coatings deposited at high temperatures are typically columnar in structure; high concentrations of the reactant gases produce oxide powders on the substrate surface. Ta<sub>2</sub>O<sub>5</sub> deposited at low temperatures consists of grains that are finer and have

significantly less porosity than that formed at high temperatures. Samples of coatings which have been produced by CVD have successfully completed preliminary testing for resistance to corrosion by Na<sub>2</sub>SO<sub>4</sub>.

## Introduction

Silicon carbide and silicon nitride materials have undergone extensive development in recent years for use in a wide variety of applications such as heat exchangers, hot gas cleanup systems, and advanced heat engines. In these types of systems, ceramics will be susceptible to hot corrosion in the form of attack by molten salts such as Na<sub>2</sub>SO<sub>4</sub> formed from NaCl present in the atmosphere and sulfur impurities in the fuel.<sup>1</sup> Long term exposure

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to these types of conditions has been shown to degrade the properties of structural ceramics.<sup>1-5</sup>

Exposed surfaces of silicon-based ceramics oxidize at high temperatures to form a layer of silica which serves to inhibit further oxidation of the ceramic.<sup>6</sup> As described by others,<sup>3,7-9</sup> this silica layer can react with the molten salt to form a sodium-silicate liquid phase at temperatures above approximately 800°C, the eutectic temperature in the sodium-silica system.<sup>10</sup> As a result, the ceramic loses its protective layer and degradation of the ceramic occurs.<sup>2,7,8</sup>

Due to the nature of the service conditions under which these ceramic components are expected to perform, it becomes necessary to protect them from corrosion. Coatings are currently being developed which may protect SiC and Si<sub>3</sub>N<sub>4</sub> components from salt-induced corrosion.

## Background

In 1986, GTE Laboratories initiated a program to develop a coating system which would protect SiC and Si<sub>3</sub>N<sub>4</sub> heat engine components from both corrosion and contact stress damage. The development of such coatings is difficult because a mismatch between the coefficient of thermal expansion (CTE) of the coating and that of the substrate can cause the coating to crack or spall. To resolve this problem, the coating system shown in Figure 1 was developed by GTE to accommodate the stresses caused by the difference in CTE.<sup>11</sup> Initially, an AlN coating was deposited onto the substrates. During the chemical vapor deposition (CVD) process, chemical interactions produced a SiAlON-type compound which provided adherence to the substrate. The coating was then compositionally graded from AlN to Al<sub>x</sub>O<sub>y</sub>N<sub>z</sub> to Al<sub>2</sub>O<sub>3</sub> + ZrO<sub>2</sub>.

Due to the absence of sharp interfaces and the gradual increase in thermal expansion from the interface to the outer Al<sub>2</sub>O<sub>3</sub> + ZrO<sub>2</sub> protective coating, residual stresses in the coating were minimized, providing a coating system which should survive in the thermal environment found in heat engines.

GTE Laboratories' coating system seemed appealing for several years.<sup>12,13</sup> However, thermal cycling of their coatings produced cracks, severely degrading their ability to protect components from oxidation. As a result, the developers of this coating system concluded that the difference in thermal expansion between SiC or Si<sub>3</sub>N<sub>4</sub> and the Al<sub>2</sub>O<sub>3</sub> + ZrO<sub>2</sub> coating is too great to develop an adherent, crack-free coating.

## Candidate Protective Coatings

Several criteria must be met in order for a material to provide corrosion protection. The first and most obvious requirement is the ability of the coating to resist reaction with an aggressive salt layer. It must also have a CTE that is much closer to that of SiC and Si<sub>3</sub>N<sub>4</sub>. More closely matched CTE's would overcome the problem of adherence as well as minimize noncatastrophic cracking which would allow molten salt to penetrate the coating and result in a loss of corrosion protection. The material must also be a stable oxide. This requirement will make the coating inherently oxidation resistant. Additionally, considerations for weight and cost must also be taken into account.

Carbon/carbon composites are well known to have potential for use in the aerospace industry. In these high temperature applications, however, they must be protected from oxidation. Yet these composites are also known to have very low thermal expansion coefficients. As a result,

after twenty years of investigation, no oxidation resistant coatings have been found that are capable of surviving the dramatic thermal cycles typical of aerospace environments. These investigations did, however, identify several materials with low CTE's that could be useful as coatings to protect SiC and Si<sub>3</sub>N<sub>4</sub>. These materials are listed in Table 1.

3Al<sub>2</sub>O<sub>3</sub> · 2SiO<sub>2</sub> (mullite) is a material that has a CTE very close to that of SiC and it has performed reasonably well in corrosion tests, corroding somewhat more severely than Al<sub>2</sub>O<sub>3</sub> but surviving significantly better than SiC.<sup>5</sup> Mullite's corrosion resistance is dependent on the absence of free SiO<sub>2</sub>, which is readily attacked by sodium-containing salts.<sup>2,7,8</sup> Because of its corrosion resistance and low CTE, mullite is currently being investigated as a material for high temperature cross-flow filters that are exposed to sodium contaminants.<sup>14</sup>

Al<sub>2</sub>TiO<sub>5</sub> also has a CTE that is quite low. It is currently being investigated as a protective coating for carbon/carbon composites and as a corrosion resistant material for turbine engine components.<sup>15</sup> Problems, however, do exist for this material. Its CTE is very anisotropic, causing significant microcracking in monolithic structures. As with GTE Laboratories' coating system, this would obviously destroy the integrity of the coating and allow both oxygen and sodium to attack the components which it is designed to protect. Additionally, Al<sub>2</sub>TiO<sub>5</sub> tends to absorb water and could degrade significantly if it were exposed to an environment containing as little as ten per cent moisture at high temperatures.

There is not a great wealth of information known about ZrTiO<sub>4</sub> or HfTiO<sub>4</sub>. However, investigations have shown the thermal expansion coefficients of these materials to be quite low.<sup>15-17</sup> ZrTiO<sub>4</sub> and

HfTiO<sub>4</sub> crystallize in orthorhombic structures which are free of transformations.<sup>18,19</sup> The structures formed by the titanate phases provide significant advantages over the destructive phase transformations experienced by ZrO<sub>2</sub> and HfO<sub>2</sub>. Having stable crystal structures, the titanate phases do not require stabilizers which could be leached out of the structure.

Even less is known about Ta<sub>2</sub>O<sub>5</sub> · 6ZrO<sub>2</sub> and Ta<sub>2</sub>O<sub>5</sub> · 6HfO<sub>2</sub>. Both materials are reported<sup>15</sup> to have low thermal expansion coefficients and each has potential for good corrosion resistance, making them promising candidates. The lack of knowledge of these materials, as well as the possible complexity in obtaining exact stoichiometries for Ta<sub>2</sub>O<sub>5</sub> · 6ZrO<sub>2</sub> and Ta<sub>2</sub>O<sub>5</sub> · 6HfO<sub>2</sub> and avoiding the production of homologous phases, pose potential problems concerning the ease with which they may be deposited.

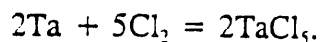
On the other hand, the ease with which Ta<sub>2</sub>O<sub>5</sub> can be deposited has already been demonstrated.<sup>20,21</sup> Additionally, phase equilibria studies of the Ta<sub>2</sub>O<sub>5</sub>-Na<sub>2</sub>O system have shown that no liquid phases are present below 1625°C, as shown in Figure 2.<sup>22</sup> Formation of either of the sodium tantalate phases at typical application temperatures that are 300 to 500°C below the liquidus temperature would seem unlikely.<sup>23</sup>

In order to protect SiC and Si<sub>3</sub>N<sub>4</sub> components, the candidate coating must also prevent the oxygen present in a combustion atmosphere from diffusing through the coating to the surface of the component. Since oxygen can diffuse through most oxides at a significant rate, another barrier to oxygen must be established. This can be provided by the native silica layer which coats silicon-based ceramics. Silica is relatively impervious to oxygen, and it should prevent oxidation of the component. However, if the silica layer should either react with or diffuse into the protective

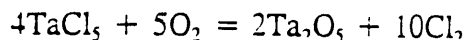
coating which is deposited on top of it, its effectiveness to stop oxygen penetration would likely be destroyed. Although phase equilibria for the system  $\text{Ta}_2\text{O}_5\text{-SiO}_2$  does not appear to be well established, the available data shows that no liquid phases exist below  $1550^\circ\text{C}$ .<sup>24</sup> As in the formation of any intermediate sodium tantalate phases, no solid state reactions are expected at temperatures 200 to  $400^\circ\text{C}$  below the liquidus temperature. To ensure compatibility between the silica layer and the protective  $\text{Ta}_2\text{O}_5$  coating, long-term testing will need to be performed.

### Experimental Procedure

Chemical vapor deposition of  $\text{Ta}_2\text{O}_5$  on SiC substrates has been performed using the experimental setup shown in Figure 3. This system is contained in a quartz tube which is sealed at both ends with stainless steel end caps. The substrate is heated inductively by heating a graphite susceptor with a radiofrequency generator. Corrected substrate temperatures in the range of 1000 to  $1300^\circ\text{C}$  are measured using an optical pyrometer by sighting through a window in the end cap. In the first stage of the reactor, chlorine gas is passed over tantalum metal in a chlorinator electrically heated to approximately  $600^\circ\text{C}$ , producing  $\text{TaCl}_5$  via



The addition of  $\text{O}_2$  through a separate inlet tube causes the gases to react at the substrate via



to produce an adherent  $\text{Ta}_2\text{O}_5$  coating on the substrate.

Sets of experiments were statistically designed using a  $2^n$  factorial method to

efficiently find the optimal deposition conditions. X-ray diffraction (XRD) techniques were used to verify the composition of the coating. Coating morphology was characterized using scanning electron microscopy (SEM) and optical microscopy.

Coatings deposited by CVD underwent preliminary testing for corrosion by  $\text{Na}_2\text{SO}_4$  using a solution of distilled water and  $\text{Na}_2\text{SO}_4$ . A drop of solution was applied to the top center face of a coated sample and dried in a drying oven, thus leaving only the salt on the coating. This was repeated until a  $\text{Na}_2\text{SO}_4$  concentration of 10 to  $20\text{ mg/cm}^2$  was obtained. Corrosion testing was performed in a four inch diameter quartz tube furnace at  $1000^\circ\text{C}$  for 100 hours with a 200 sccm flow of air passing over the specimens. Samples were then analyzed using XRD and SEM techniques.

### Results and Discussion

The morphology of the  $\text{Ta}_2\text{O}_5$  coating was strongly dependent on the deposition conditions. The statistically designed experiments examined the effects of system pressure, argon gas flow rate, substrate temperature, and oxygen and chlorine gas flow rates. Initial experiments over a range of substrate temperatures and gas flow rates indicated that regardless of substrate temperature or gas flow rates, consistently denser deposits of  $\text{Ta}_2\text{O}_5$  were being formed at pressures of approximately 6.67 kPa (50 Torr) and using 40 sccm of argon to dilute the reactant gases. As a result, pressure and argon flow were fixed at these two values during the investigation. Gas flows for oxygen and chlorine ranged from 8 to 20 and 1 to 5 sccm, respectively.

Substrate temperatures of  $1300^\circ\text{C}$  produced coating structures which contained large, columnar grains with considerable

intergranular passages. This structure can be seen in the optical and scanning electron microscope photographs shown in Figure 4. Obviously, this coating could do little to protect SiC or Si<sub>3</sub>N<sub>4</sub> from the corrosive environment found in heat engines. Liquid Na<sub>2</sub>SO<sub>4</sub> could flow in between the columnar grains with ease, attack and dissolve the SiO<sub>2</sub> coating the ceramic component, and subsequently attack the component itself.

Ta<sub>2</sub>O<sub>5</sub>, which was produced with high concentrations of reactants - an oxygen to chlorine to argon ratio of 10 to 3 to 40 - produced powders on the substrate surface. These can be seen in Figure 5. Even though most of the powders adhered to the substrate well enough to be examined by microscopy, it is certain that they would not be able to withstand the high pressure combustion environment, loaded with abrasive particulates, found in an engine.

At lower temperatures and with more dilute concentrations of reactant gases, more coherent coatings have consistently been produced which contain more equiaxed grains. As shown in Figure 6, these coatings are very uniform and continuous in structure. Unlike the morphologies described previously, they likely would not allow molten salts a direct path to the substrate surface.

Additional work is currently underway to further optimize coating morphology. The aim of refinements to the Ta<sub>2</sub>O<sub>5</sub> structure is to produce finer, more equiaxed grains. Reducing grain size would increase the diffusion path along grain boundaries to the substrate surface. If oxygen diffusion occurs along grain boundaries, a reduction in grain size would increase the time required for oxygen transport across the coating. Residual coating stresses due to anisotropy in the coefficient of thermal expansion would also be minimized with a reduction in grain size. Coating morphologies such as these promise

to protect the ceramic components in heat engines.

Preliminary corrosion tests using 15 mg/cm<sup>2</sup> of Na<sub>2</sub>SO<sub>4</sub> in contact with CVD deposited Ta<sub>2</sub>O<sub>5</sub> demonstrated that no apparent reaction occurred between the coating and the molten salt. As shown in the upper left corner of Figure 7, the Ta<sub>2</sub>O<sub>5</sub> coatings which were tested consisted mainly of columnar grains and whiskers. Despite the coating morphology, no interaction of the coating or substrate with the molten salt seems to have taken place. An examination of Figure 7 indicates that the Na<sub>2</sub>SO<sub>4</sub> in the lower right corner melted upon heating past its melting point and wetted the surface of the Ta<sub>2</sub>O<sub>5</sub> coating. At the end of the corrosion test, the salt simply recrystallized as a polycrystalline film on the coating surface. These results were confirmed by X-ray diffraction, which identified SiC and Ta<sub>2</sub>O<sub>5</sub> as the phases present. To more completely determine the suitability of Ta<sub>2</sub>O<sub>5</sub> coatings, however, additional work is needed to test and subsequently analyze specimens under similar conditions for up to 1000 hours.

## Conclusions

SiC and Si<sub>3</sub>N<sub>4</sub> heat engine components are susceptible to hot corrosion by molten Na<sub>2</sub>SO<sub>4</sub> salts which are formed from impurities in the engine's fuel and air intake. A number of oxides have been identified which may protect these components from corrosion. Among these, Ta<sub>2</sub>O<sub>5</sub> was selected as one of the most promising candidates, and chemical vapor deposition techniques have been developed to deposit it onto SiC substrates. Depending on the deposition conditions, a variety of coating morphologies have been produced, and conditions have been identified which produce dense, continuous Ta<sub>2</sub>O<sub>5</sub> deposits.

These conditions are being further optimized to produce a finer, more equiaxed microstructure. Additionally, preliminary corrosion tests with 15 mg/cm<sup>2</sup> of Na<sub>2</sub>SO<sub>4</sub> at 1000°C showed no degradation of the CVD deposited coatings of Ta<sub>2</sub>O<sub>5</sub>.

## References

1. J. J. Swab and G. L. Leatherman, "Static-Fatigue Life of Ce-TZP and Si<sub>3</sub>N<sub>4</sub> in a Corrosive Environment," *J. Am. Ceram. Soc.*, **75** [3] 719-21 (1992).
2. J. L. Smialek and N. S. Jacobson, "Mechanism of Strength Degradation for Hot Corrosion of  $\alpha$ -SiC," *J. Am. Ceram. Soc.*, **69** [10] 741-52 (1986).
3. N. S. Jacobson and D. S. Fox, "Molten-Salt Corrosion of Silicon Nitride: II, Sodium Sulfate," *J. Am. Ceram. Soc.*, **71** [2] 139-48 (1988).
4. N. S. Jacobson, J. L. Smialek, and D. S. Fox, "Molten Salt Corrosion of SiC and Si<sub>3</sub>N<sub>4</sub>," pp. 99-136 in *Handbook of Ceramics and Composites, Vol. 1: Synthesis and Properties*. Edited by N. P. Cheremisinoff. Dekker, New York, 1990.
5. J. I. Federer, "Corrosion of SiC Ceramics by Na<sub>2</sub>SO<sub>4</sub>," *Adv. Ceram. Mater.*, **3** [1] 56-61 (1988).
6. J. A. Costello and R. E. Tressler, "Oxidation Kinetics of Hot-Pressed and Sintered  $\alpha$ -SiC," *J. Am. Ceram. Soc.*, **64** [6] 327-31 (1981).
7. N. S. Jacobson and J. L. Smialek, "Hot Corrosion of Sintered  $\alpha$ -SiC at 1000°C," *J. Am. Ceram. Soc.*, **68** [8] 432-39 (1985).
8. N. S. Jacobson, C. A. Stearns, and J. L. Smialek, "Burner Rig Corrosion of SiC at 1000°C," *Adv. Ceram. Mater.*, **1** 154-61 (1986).
9. D. S. Fox and N. S. Jacobson, "Molten-Salt Corrosion of Silicon Nitride: I, Sodium Carbonate," *J. Am. Ceram. Soc.*, **71** [2] 128-38 (1988).
10. E. M. Levin, C. R. Robbins, and H. F. McMurdie, p. 94 in *Phase Diagrams for Ceramists*, The American Ceramic Society, Westerville, OH, 1964.
11. V. K. Sarin, "Design Criteria for a Coating to Reduce Contact Stress Damage," in *Proceedings of the DOE Workshop on Coatings for Advanced Heat Engines*, Castine, ME, July, 1987.
12. H. E. Rebenne and V. K. Sarin, "Ceramic Coatings to Reduce Contact Stress Damage of Ceramics - Thermodynamic Modeling," pp. 199-206 in *Proceedings of the 25th Automotive Technology Development Contractors' Coordination Meeting*, Society of Automotive Engineers, P-209, Warrendale, PA, 1988.
13. H. E. Rebenne and J. H. Selverian, "Adherent Ceramic Coatings to Reduce Contact Stress Damage of Ceramics," pp. 227-38 in *Proceedings of the Annual Automotive Technology Development Contractors' Coordination Meeting*, Society of Automotive Engineers, P-243, Warrendale, PA, 1991.
14. M. A. Alvin, D. M. Bachovchin, J. E. Lane, and R. E. Tressler, "Degradation of Cross Flow Filter Material," pp. 162-

- 7 in *Proceedings of the Seventh Annual Coal-Fueled Heat Engines and Gas Stream Cleanup Systems Contractors' Review Meeting*, Rept. No. DOE/METC-90/6110. Edited by H. A. Webb, et al., U. S. Dept. of Energy, Morgantown, WV, 1990.
15. M. Milosevski, et al., "Influence of Some Oxides on the Thermal Expansion Characteristics of  $\text{Al}_2\text{TiO}_5$ ," *Proceedings of the 4th International Symposium on Ceramic Materials and Components for Engines*, to be published.
  16. I. Y. Glatter, D. J. Treacy, J. E. Sheehan, and K. S. Mazdidasni, "High Temperature Chemical Behavior of a Multi-Layered Oxidation Protection Coating System for Carbon-Carbon Composites," Wright Research Development Center, Rept. No. WRDC-TR-89-4127, 1989.
  17. R. Ruh, et al., "Phase Relations and Thermal Expansion in the System  $\text{HfO}_2$ - $\text{TiO}_2$ ," *J. Am. Ceram. Soc.*, **59** [11-12] 495-99 (1976).
  18. K. S. Mazdidasni and L. M. Brown, "Preparation and Characterization of High Purity  $\text{HfTiO}_4$ ," *J. Am. Ceram. Soc.*, **53** [11] 585-9 (1970).
  19. E. M. Levin and H. F. McMurdie, p. 169 in *Phase Diagrams for Ceramists, 1975 Supplement*, American Ceramic Society, Westerville, OH, 1975.
  20. T. Takahashi and H. Itoh, "Formation of Tantalum Oxide by Chemical Vapor Deposition," *J. of Less Common Metals*, **38** 211-19 (1972).
  21. E. Kaplan, M. Balog, and D. Frohman-Bentchkowsky, "Chemical Vapor Deposition of Tantalum Pentoxide Films for Metal-Insulator-Semiconductor Devices," *J. Electrochem. Soc.: Solid-State Science and Technology*, **123** [10] 1570-3 (1976).
  22. E. M. Levin and H. F. McMurdie, p. 92 in *Phase Diagrams for Ceramists, 1975 Supplement*, American Ceramic Society, Westerville, OH, 1975.
  23. D. W. Richerson, pp. 113 and 116-8 in *Modern Ceramic Engineering, Second Edition*, Dekker, New York, 1992.
  24. E. M. Levin and H. F. McMurdie, p. 167 in *Phase Diagrams for Ceramists, 1975 Supplement*, American Ceramic Society, Westerville, OH, 1975.

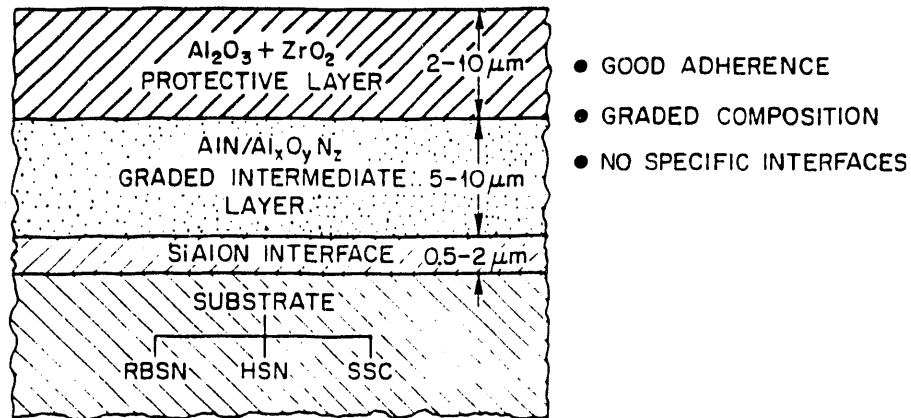


Figure 1  
GTE's Protective Coating

Table 1  
Refractory Oxides with Potential for Oxidation/Corrosion Protection

Compound	Density ( $\text{g}/\text{cm}^3$ )	CTE ( $\times 10^{-6}/^\circ\text{C}$ )
$\text{Al}_2\text{O}_3$ *	3.97	8.0
$3\text{Al}_2\text{O}_3 \cdot 2\text{SiO}_2$	2.8	5.7
$\text{SiC}$ *	3.21	5.5
$\text{ZrTiO}_4$	$\approx 5$	$\approx 4$
$\text{HfTiO}_4$	$\approx 5$	$\approx 4$
$\text{Ta}_2\text{O}_5 \cdot 6\text{ZrO}_2$	$\approx 6$	$\approx 4$
$\text{Ta}_2\text{O}_5 \cdot 6\text{HfO}_2$	$\approx 6$	$\approx 4$
$\text{Ta}_2\text{O}_5$	8.02	3.6
$\text{Si}_3\text{N}_4$ *	3.19	3.0
$\text{Al}_2\text{TiO}_5$	3.68	2.2
Carbon/carbon *	1.9	$\approx 0$

\* Included only as a reference and not as a potential coating

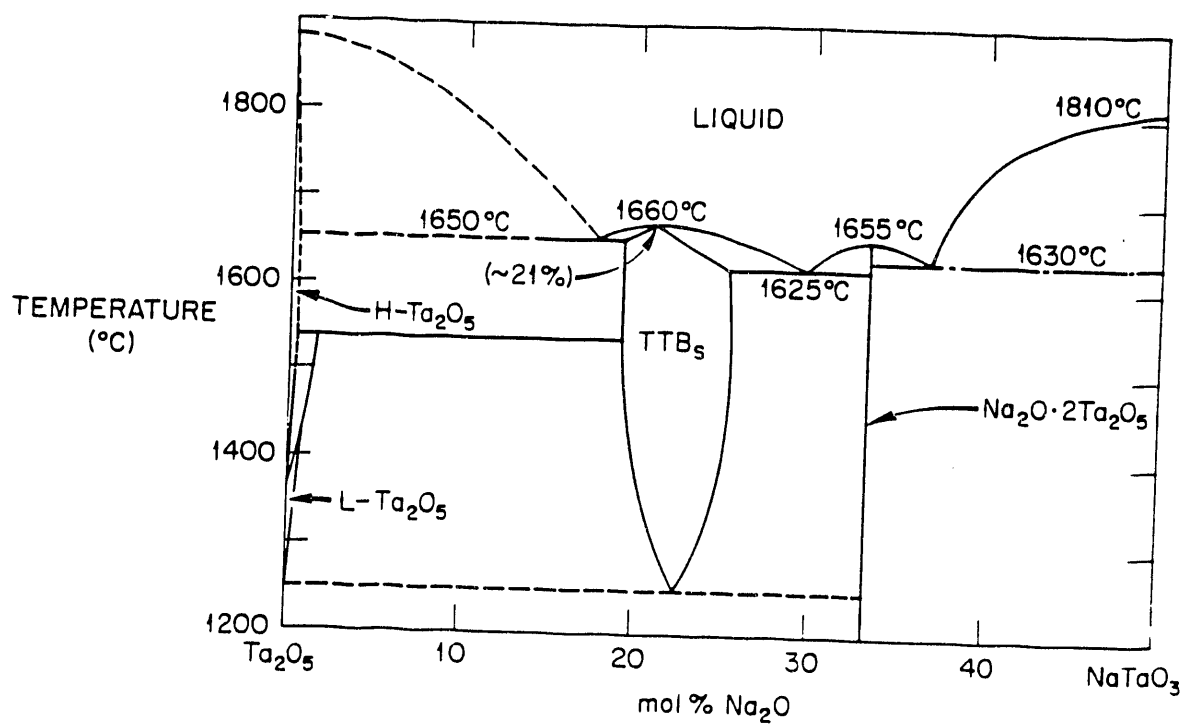


Figure 2  
 $\text{Ta}_2\text{O}_5$ - $\text{Na}_2\text{O}$  Phase Diagram

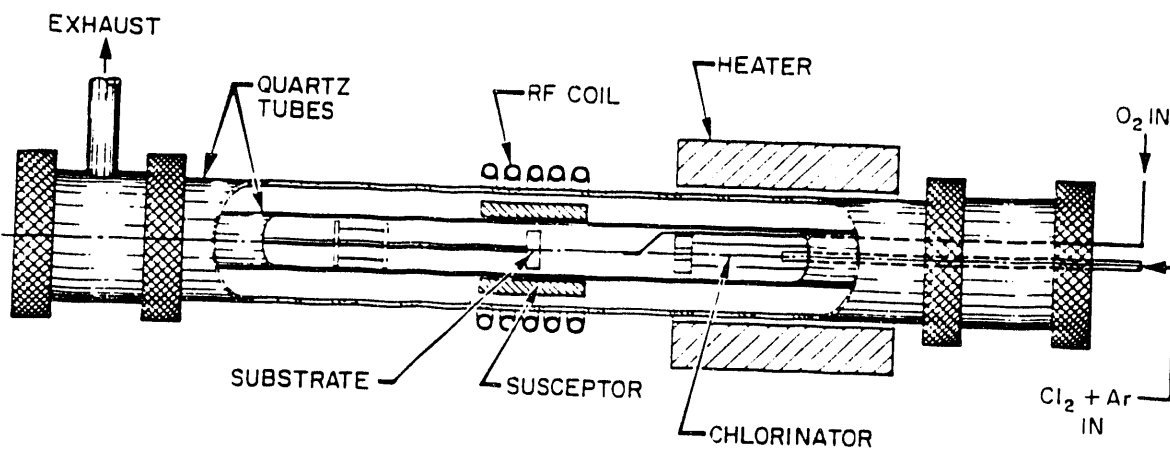
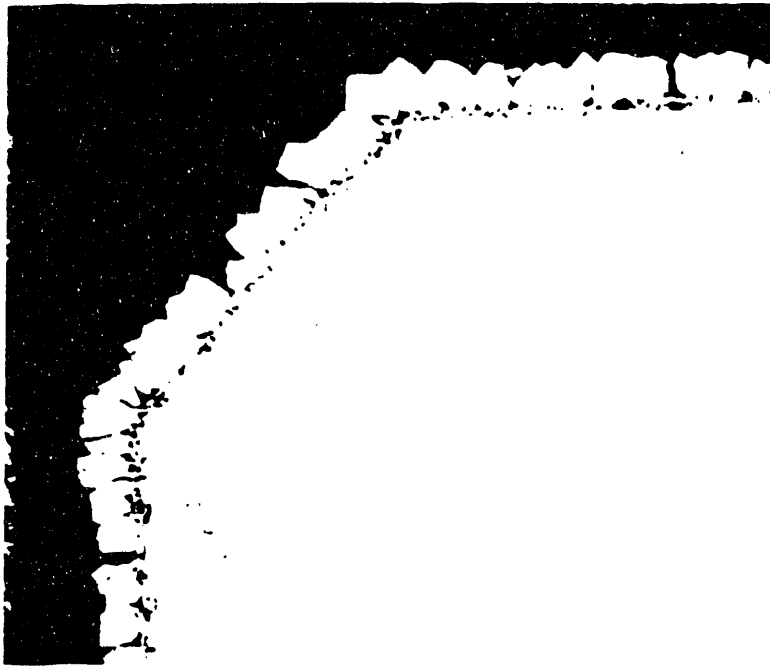


Figure 3  
Schematic of CVD Reactor



(a) Photomicrograph of a section through the  $\text{Ta}_2\text{O}_5$  coating and SiC substrate, as polished

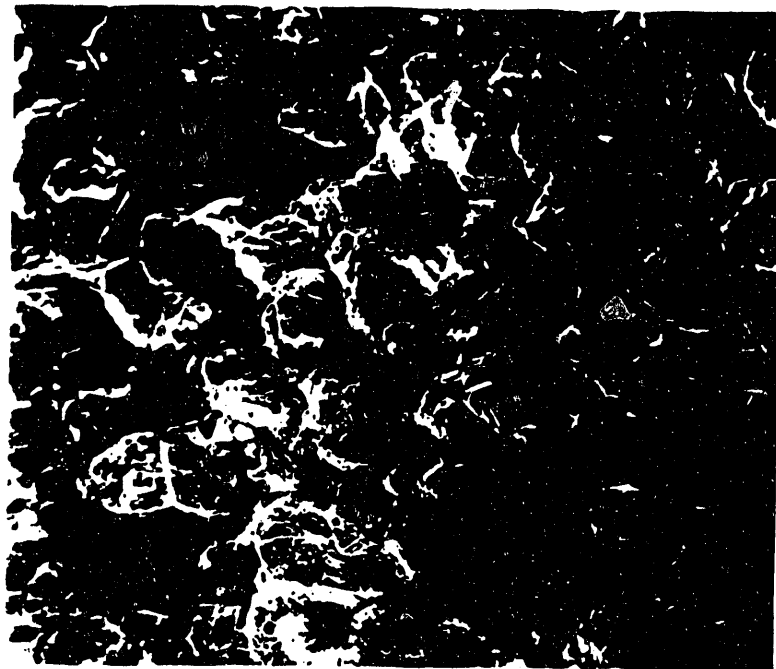


(b) Scanning electron micrograph of the as-deposited  $\text{Ta}_2\text{O}_5$  coating

Figure 4  
Coating Morphology Produced by High Deposition Temperatures



(a) Photomicrograph of a section through the  $\text{Ta}_2\text{O}_5$  coating and SiC substrate, as polished



(b) Scanning electron micrograph of the as-deposited  $\text{Ta}_2\text{O}_5$  coating

Figure 5  
Coating Morphology Produced by High Reactant Concentrations



(a) Photomicrograph of a section through the  $\text{Ta}_2\text{O}_5$  coating and SiC substrate, as polished



(b) Scanning electron micrograph of the as-deposited  $\text{Ta}_2\text{O}_5$  coating

Figure 6  
Coatings Produced Using Low Temperatures and Low Reactant Concentrations



15  $\mu\text{m}$

Figure 7  
Scanning electron micrograph of the Ta<sub>2</sub>O<sub>5</sub> and Na<sub>2</sub>SO<sub>4</sub> interface after corrosion testing

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